## JUL 0 5 2006

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

SHIMBORI et al.

Docket No.:

372106-105 (338531)

Serial No.

10/628,919

Art Unit:

1756

Filed:

July 29, 2003

Examiner:

Young, Christopher G.

Title:

PHOTORESIST PATTERN AND FORMING METHOD THEREOF

Mail Stop AF Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

RESPONSE & AMENDMENT UNDER 37 CFR 1.116

NOT PLATER JOHN 7/18/06

Dear Sir:

In response to the Final Office Action mailed April 4, 2006, Applicants submit the following amendments and remarks.

Amendments to the claims begin on page 2 of this paper.

Remarks/Arguments begin on page 3 of this paper.